

CLAIMS:

1. A method for determining a pose of an implant object that is located inside a human or animal body, on the basis of a CAD model of that implant object through a reconstruction X-Ray procedure viz à viz the implant object,

said method being characterized by comprising for an implant object that has a

5 degree of symmetry according to an n-dimensional structure of symmetry the steps of:

generating a first measurement configuration and a second measurement configuration regarding an X-Ray source and a prespecified implant object position, and generating a first and a second implant shadow, respectively;

assuming for each said first and second measurement configuration an

10 instance of said n-dimensional structure of symmetry;

calculating for each of said first and second measurement configuration from said shadow a pair of alternative poses of said implant object as being symmetrical with respect to said n-dimensional structure;

and finding among said pairs of alternative poses two matching poses that

15 thereby produce an angle information with respect to said n-dimensional structure of symmetry of said implant object.

2. A method as claimed in Claim 1, wherein said n-dimensional structure of mirror symmetry is a plane.

20

3. A method as claimed in Claim 1, wherein said n-dimensional structure of symmetry is a straight line.

25 4. A method as claimed in Claim 3, wherein said straight line is an axis of rotary symmetry of said implant object.

5. An apparatus being arranged for implementing a method as claimed in Claim 1 for determining a pose of an implant object that is located inside a human or animal body,

on the basis of a CAD model of that implant object through a reconstruction X-Ray procedure viz à viz the implant object,

said apparatus comprising for an implant object that has a degree of symmetry according to an n-dimensional structure of symmetry the following facilities:

5 a measuring facility for generating a first measurement configuration and a second measurement configuration regarding an X-Ray source and a prespecified implant object position, and for generating a first and a second implant shadow, respectively;

10 data processing means for through assuming for each said first and second measurement configuration an instance of said n-dimensional structure of symmetry and calculating for each of said first and second measurement configuration from said shadow a pair of alternative poses of said implant object as being symmetrical with respect to said n-dimensional structure;

15 and matching means for finding among said pairs of alternative poses two matching poses that thereby produce an angle information with respect to said n-dimensional structure of symmetry of said implant object.